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Silicon photonics interfaced with microelectronics for integrated photonic quantum technologies: a new era in advanced quantum computers and quantum communications?

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Silicon photonics is rapidly evolving as an advanced chip framework for implementing quantum technologies. With the help of silicon photonics, general-purpose programmable networks with hundreds of discrete components have been developed. These networks can compute quantum states generated onchip as well as more extraordinary functions like quantum transmission and random number generation. In particular, the interfacing of silicon photonics with complementary metal oxide semiconductor (CMOS) microelectronics enables us to build miniaturized quantum devices for next-generation sensing, communication, and generating randomness for assembling quantum computers. In this review, we assess the significance of silicon photonics and its interfacing with microelectronics for achieving the technology milestones in the next generation of quantum computers and quantum communication. To this end, especially, we have provided an overview of the mechanism of a homodyne detector and the latest stateof-the-art of measuring squeezed light along with its integration on a photonic chip. Finally, we present an outlook on future studies that are considered beneficial for the wide implementation of silicon photonics for distinct data-driven applications with maximum throughput.

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Introduction L

Silicon photonics (SiP) is considered instrumental in advancing cutting-edge chip platforms for quantum computing. 1,2 This technology platform is being used to make general programmable networks with hundreds of separate components that can compute quantum states generated on-chip, as well as more specific applications like the creation of random numbers of quantum and quantum transmission.^{3,4} Quantum information can be programmed in different various states during quantum communication. However, photonic states have gained significant attention for quantum communication as their lack of interaction with the external environment, low noise, and lightspeed transmission.⁵ Based on previous research, it has been observed that quantum communication requires only one quantum channel for information transmission. Quantum information processing (QIP) utilizes the photon states for information processing, computation, storage, and transmission.⁷ Silicon photonics assist any device in realizing the QIP task with the utilization of single-qubit operations, 8,9 and fundamentally it has proven that entanglement operations need to be appropriate for implementing QIP with quantum control. 10,111

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Nanoscale Review

Recent advancements in silicon photonics have resulted in high-performance building blocks including detectors, modulators, multiplexer (Mux)/de-multiplexer (Demux), switches, which are ideal for optoelectronic integration with CMOS systems for optical interconnections. 12,13 Furthermore, silicon photonics is recognized as a pioneering technology that has driven advanced breakthroughs in the area of data communication. telecommunication, sensing, security. 14,15 The significant element behind silicon photonics is its capability of realizing highly integrated, small, and photonic sub-systems. An important factor for the scalability of these systems can be achieved by applying CMOS-based microfabrication technologies. 16,17 Moreover, silicon photonics with CMOS electronics empowers the realization of low-cost devices that can achieve high-speed sensing and also perform complex computations efficiently. 18,19

Fig. 1 shows a schematic illustration of silicon photonics with CMOS for realizing low-cost devices and achieving complex computing-based operations. In the area of the data center, communication, computer, and telecom, silicon photonics assist in building devices that are capable of implementing high-speed data communication with low power consumption. It is believed that the core-to-core communication will be improved in processor technology by shifting from multicore to many-core communications. 20,21 As each core operates at speeds of a gigabyte per second (GB s⁻¹), photonic interconnection integrated into an intra-chip achieves and handles GB s⁻¹ or terabytes per second (TBps).^{22,23} Because of its unique signal propagation method, the photonic interconnection will be able to reach such a maximum speed without signal interference or power consumption concerns. 24,25 Concerning broader application perspectives, it is believed that the inclusion of quantum computing in the data center will empower security and networking aspects. For example, quantum networking will enable the direct ability to interact

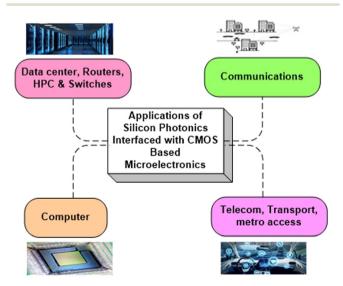


Fig. 1 Applications silicon photonics with CMOS-based microelectronics.

with the gigantic computational power of quantum computers and the exchange of information while remaining within the realm of the quantum world.26 The transformation of data teleportation will allow for highly scalable and energy-efficient networks while also preserving data security at every physical layer via quantum encryption. As a result, quantum computing in transportation allows us to imagine more sustainable cities where cars, buses, and pedestrians are routed in real-time in the safest, most efficient ways.²⁷ The advantages of quantum computing are manifold. For instance, routing optimization has the following applications: it decreases the amount of time people spend in traffic, increases safety, lowers pollution, and helps city planners better visualise the impact of large-scale infrastructure projects like public transportation. Furthermore, quantum computing has a significant impact on basic sciences as well, where it can deliver a multitude of functions such as energy efficiency and carbon management in the area of renewable energy.²⁸ In renewable energy sectors, quantum computing is useful for the optimization of materials and the infrastructure in the energy sector with simulation for complex energy system processes.

The integration of silicon photonics and electronics is categorized into two types namely: hybrid integration²⁹ and monolithic integration.³⁰ Photonic components are equipped on a single chip in hybrid integration.³¹ In monolithic integration, photonic devices and electronics are linked on a single chip in monolithic integration.³² In monolithic integration, silicon is recognized as a material that is significantly suitable for the integration of optics and photonics.³³ During the integration process, for achieving the maximum level of photonic function integration, light needs to be limited in submicron waveguides with a medium $(\Delta n \sim 0.5)$ to large $(\Delta n \sim 2)$ refractive index between the clap and the cladding.³⁴ The majority of experiments relied on the utilization of silicon on insulator (SOI) substrates because CMOS technology has been adopted by them.35

In this review, we present the mechanism of interfacing silicon photonics with microelectronics and discuss the integration of photonics with electronic parts. The different methodologies that are involved during integration are briefly addressed. In the first step, the measurement of squeezing light is addressed as it significantly assists in building modern quantum technology. Subsequently, we discuss the integration of a homodyne detector on a photonic chip. The mechanism for utilizing a homodyne detector for amalgamating a silicon microelectronics chip with a photonic chip is also presented, where a homodyne detector device is utilized for squeezing the fiber-coupled source.

The organization of the article is as follows: section II covers an overview of silicon photonics; section III covers the measuring squeezed light; section IV covers the homodyne detector; section V covers the interfacing of microelectronics with silicon photonics; section VI covers the squeezing source with fiber-coupled; and section VII covers the future perspectives along with conclusion in the final section.

II. Overview of silicon photonics

Photonic devices are extensively utilized in a variety of fields, including physics, energy, and information technology. 36 Among the several materials of option, silicon has attracted the attention of both the academics and industry. In order to achieve a high integration density, cost-effectiveness, and the maximum yield, silicon photonics relies on the traditional CMOS manufacturing process. 37 The three matured silicone family substances that are frequently used in photonics research and development are silicon nitride (Si₃N₄), silicon, and silica (SiO₂). 38 Fig. 2 illustrates the material absorption features of the three materials. The silicon material possesses the minimum wavelength absorption ranging from 1.1–8.5 micrometer (μ m) to the mid-infrared (MIR) and near-infrared (NIR) regions. 39,40

Silicon nitride is a material that can be used to implement silicon photonics at wavelengths less than 1.1 $\mu m.^{41}$ It is concluded by researchers that silica is an appropriate element for planar lightwave circuits (PLCs) as it features a low propagation loss. 42 The refractive indices and non-linear coefficients for SiO2, Si3N4, and silicon materials in the spectrum of NIR are described in Table 1. Silicon products have the maximum refractive index, resulting in a maximum index contrast for silicone waveguides and an extremely compact footprint. The high silicon thermo-optic (TO) coefficient enables silicon wavelength systems very sensitive to differences in the temperature specifically for micro-activity devices.

Silicon photonics provides an optical path for all communication blocks and connections. It allows for the deployment of

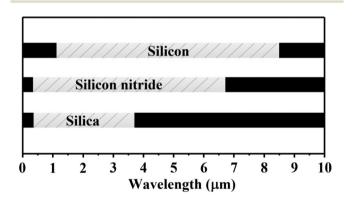


Fig. 2 Material absorption characteristics reproduced with permission⁴¹ Copyright 2020, Wiley.

Table 1 Optical properties of SiO₂, Si₃N₄, and silicon materials

Material	Index of refraction	Kerr non-linearity $[m^2 W^{-1}]$	TO coefficient $[K^{-1}]$
Silica ⁴²	1.444	2.2×10^{-20}	0.95×10^{-5}
Silicon nitride ⁴³	2.0	2.45×10^{-19}	2.45×10^{-5}
Silicon ⁴⁴	3.467	4.4×10^{-18}	1.86×10^{-4}

greater silicon IC equipment. The low losses (<1 dB m⁻¹ loss achieved), as the fundamental component of the silicon photonic chip connecting all photonic components, enabling the creation of an optical chip by a mixture and match of several functional devices. Silicon, silicon-nitride, and silica are included in these waveguides depending on the application. Chip-based applications employ silicon photonics as a basic building component for waveguide connections using an optical fiber to create an optical input/output (I/O). The input and output connectors can be vertical or threshold, with tape to broaden the mode and properly align mono-mode fibers.

The monolithic silicon platform may integrate and interconnect photonic devices with diverse functions, such as photodetectors and modulators, depending on the waveguide system. 50 Furthermore, heterogeneous integration using III-V materials gives the chip's optical lasers and amplifiers, the necessary rise channels. An essential part of silicon photonics was the optical modulator, which was crucial to the success of the promotion of the technology. A variety of systems have been established to offer rapid speed light modulation from an electrical source. The Mach-Zehnder modulator (MZM) is the most popular technique proved in mass production. This modulator is extremely responsive to the temperature and has a very broad modulation bandwidth. To considerably expand the bandwidth of optical modulators, heterogeneous integration permits the use of III-V materials and lithium niobate.

III. Measuring squeezed light

Photonic technology for quantum information processing focuses heavily on squeezed light sources.⁵¹ Squeezing is crucial for quantum computing and quantum sensing. These light sources are dependent on waveguides with periodic poles and are mounted on platforms with low-index contrast.52 The development of modern quantum technology is largely dependent on silicon photonics taking advantage of its sophisticated photonic chip platform.⁵³ A monolithic assembly of both the quantum hardware and the corresponding microelectronics for classical control and readout is regarded to be the key to enhancing this type of photonic quantum technology.⁵⁴ Researchers have demonstrated that hundreds of separate components may be used to handle quantum states synthesized on-chip using general-purpose programmable networking.55 However, device scalability along with performance is somewhat limited due to the classical interface hardware that is still employed for integrated quantum photonics with large-footprint discrete electronics. 56,57 Integration of silicon quantum photonics or photonic quantum technologies with monolithic CMOS circuits is required to achieve the desired device functionality and scalability.58-60 The adoption of CMOS compatibility is thought to minimize the overall device footprint, allowing maximum performance classical control, and readout resources to scale with quantum technology.61

Nanoscale Review

Therefore, current research in photonic quantum technology focuses on exploiting the unique properties of quantum physics and technology. The goal is to create innovative routes to take the current state-of-the-art in computing, communication, and measurement to the next level. Taking advantage of silicon photonics which uses light as a carrier of information in silicon microchips, new avenues are being explored for developing these next-generation technologies. To this end, squeezed light, which is a quantum effect, is considered very useful to realize these advanced technologies. It is believed that the application of squeezed light can play a pivotal role in quantum communications and quantum computers.

Current research and development efforts are aimed at improving the ways of measuring squeezed light which is considered to have a big impact on these technologies. Heasuring squeezed light requires advanced detectors and these detectors require to be specially engineered for ultra-low electronic noise to identify the weak quantum features of light. Developing this capability could significantly boost the processing speed of emergent information technologies like optical computers and light-based communications. He are a simple of the second second detectors.

Furthermore, the higher bandwidth of the detector can result in much faster performance with calculations and information transmission. However, the principle challenge is the limitation of these detectors to measure the speed of signals, which is required to measure about one thousand million cycles per second to achieve the goal. An advanced concept in measuring squeezed light on the basis of homodyne detector and chip-scale approach. It is concluded the homodyne detector performance is improved. 88,69

IV. Homodyne detector

Homodyne detectors are used to estimate quantum states and to represent quantum processes. They are essentially hardware that is intended to measure light in a sensitive manner. Quantum-secured communication, coherent Ising machines, quantum state and process tomography, dual-comb spectroscopy, random number generation, and quantum computing are some of the applications of homodyne detectors. Furthermore, research has revealed that homodyne detectors can be used to improve the performance of recently suggested optical neural networks that operate below the Landauer limit. However, as we described in the beginning, the speed performance of many applications is usually constrained by the utilization of electronic circuits and non-monolithic photonics.

Recent research advances have suggested the use of integrated photodiodes that are considered promising for increasing the homodyne detector bandwidth that could potentially result in tens of gigahertz (GHz) speed performance enhancement.⁷⁴ Researchers have shown such potential applications for classical silicon photonic interconnects. It has also been

shown that for shot-noise-constrained applications including quantum technology, the integrated approach is usually limited to 150 megahertz (MHz) due to the implementation of transimpedance amplifiers (TIAs) with discrete electronic components. TIAs are necessary to magnify the feeble photocurrent subtraction of the two photodiodes with minimum noise. This configuration results in parasitic capacitance, which increases the noise of the circuit. This subsequently limits the bandwidth of the overall detector, which prevents the \sim 10 s GHz raw performance of integrated photodiodes.

Researchers showed that the optical integration of a homodyne detector onto a silicon photonics chip and the resulting device was shown to be compact and operated at high speeds up to 150 MHz with low noise.76 A low-cost system for continuous-variable quantum key distribution (CV-QKD) is implemented with a fiber optical communication infrastructure on a silicon photonic chip and achieved a secret key rate of 0.14 kbps over a simulated distance of 100 km in fiber.⁷⁷ On-chip quantum tomography of coherent states using the homodyne detector was used to characterize the general quantum states of light with a quantum random number output of 1.2 Gbps. 69 The vacuum condition of the electromagnetic field was measured, and offline post-processing was used to achieve this. Furthermore, the generated random numbers were demonstrated to pass all of the NIST test suite's statistical tests. Fig. 3(a) shows the optical input characterization setup with a 1550 nm CW laser source. A 99/1 beam splitter transmits 99 percentage of light on the LO channel and the remaining portion into the signal channel. The PM package includes a variable optical attenuator (VOA) and an off-chip phase modulator. These are used to adjust the phase and amplitude of coherent states when the tomography of coherent states is performed.

As demonstrated in Fig. 3(b), the silicon photonics homodyne detector is shown with its beam-splitting operation. Using a multi-mode interferometer (MMI) with two on-chip Ge photodiodes, this is achieved. An off-chip TIA amplifies the currents by subtracting them from each other. Fig. 3(c) shows an approach for generating random numbers using optical vacuum states as an input. It is based on the homodyne detector's bottom port, which is closed because no optical beam is available. The LO is then infused from the top port, where the optical power of the LO at the photodiodes can be maximized using a polarization controller. Researchers used the iSiPP25G IMEC technology to construct the reported photonics device on an SOI chip as part of a multi-project wafer run organized by IMEC foundry services (Fig. 3).⁷⁸ The beam was split using a multi-mode interference (MMI) device with two single-mode input waveguides and two identical single-mode output waveguides.⁷⁸ This was performed by applying a 1550 nm laser source to one of the waveguides in the MMI and using a grating coupler to couple the laser to that waveguide⁷⁹ and if the laser is attenuated, it serves as the source of the coherent state that is monitored using a detector. Moreover, we have illustrated the technical attributes of the homodyne detector

Review Nanoscale

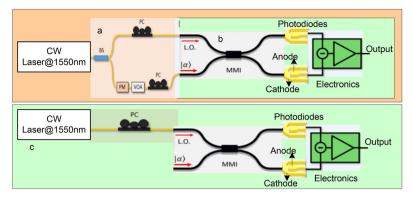


Fig. 3 Schematic depiction of the homodyne detector setup. 69

Table 2 Technical attributes of the homodyne detector

Attributes	Details	
Electrical filter for channel selection	Yes	
Local oscillator laser at a receiver	Yes	
Polarization control	Yes	
Narrowband filtering	No	
Balanced optical receivers for quadrature detection	2	
Number of degrees of freedom	1 (magnitude)	
Electrical bandwidth required for a balanced optical receiver	$\sim R_{\rm s}$	

in Table 2. A die-level balanced homodyne receiver with a 40 dB CMRR up to 1 GHz is presented for coherent optical access and continuous-variable quantum applications. A 3 GHz bandwidth die-level balanced homodyne detector with a significant quantum-to-classical noise removal of 19.1 dB was obtained. A customized integrated TIA constructed in a 100 nm GaAs pHEMT technology was utilized in this co-integrated balanced homodyne detector. A hybrid packaging was employed to amalgamate an InGaAs homodyne detector, a high-bandwidth TIA, and a photonic integrated circuit optimized for vacuum state quantum random number generator (QRNG) implementation.

V. Interfacing of silicon microelectronics with silicon photonics

Researchers recently showed that integrating silicon nanophotonics with microelectronics improved the performance of homodyne detectors. These were used to measure non-classical light whilst miniaturizing the detector's footprint to submm. This was achieved in CMOS-compatible technology for the scale-up of the process. Anophotonics on s germanium and silicon was interconnected using integrated silicon and germanium amplifiers (Fig. 4). A homodyne detector's overall capacitance was reduced, resulting in faster quantum light measurement. The detector was implemented with a 3 dB bandwidth of 1.7 GHz and a shot noise limit of 9 GHz, as

well as a 0.84 mm² minimized necessary footprint. Using a CW laser, researchers squeezed light sources from 100 MHz to 9 GHz and measured the spectrum using the detector; moreover, it is also used to perform state tomography. ⁸⁶ Fast homodyne detectors utilized for quantum optics of continuous-variable were developed as a result of this work. These results pave the way for the development of photonic quantum devices with complete stack integration.

The Integration of two silicon chips resulted in the creation of the photonic quantum device. At record-breaking speeds, this setup was utilized to calculate the peculiar features of squeezed quantum light. It was shown that coupling a siliconphotonic homodyne detector with a microelectronics amplifier can improve its performance. The 1.7 GHz bandwidth achieved was an order of magnitude higher than the earlier fastest incorporated silicon-germanium experiment. In all conventional homodyne detection, the measured shot noise above 9 GHz revealed the possibility for an order of magnitude larger bandwidth than the present one.87 The schematic of the amplifier is shown in Fig. 4(a), with each stage consisting of a common source amplifier guided by a source follower with a current source and a level shifting Schottky diode. The voltages are sensed by two large resistors, so they do not affect the circuit's high-frequency behavior. This voltage difference is used to tune the MZM on the photonic integrated circuit (PIC) to achieve appropriate balancing. The manufactured devices are shown in Fig. 4(b), with the PIC on the left and the TIA on the right.

VI. Squeezing source with fiber-coupled waveguide chip

Measurement of squeezed light and states formed from squeezed light using non-Gaussian techniques is required in quantum optics applications. Researchers evaluated broadband squeezed light created from a fiber-coupled periodically poled lithium niobate (LN) ridge waveguide chip using a homodyne detection device (Fig. 5). CW pump laser is concentrated at 1560.61 nm. It is initially boosted with an erbium-doped fibre amplifier (EDFA) before being separated into

Nanoscale Review

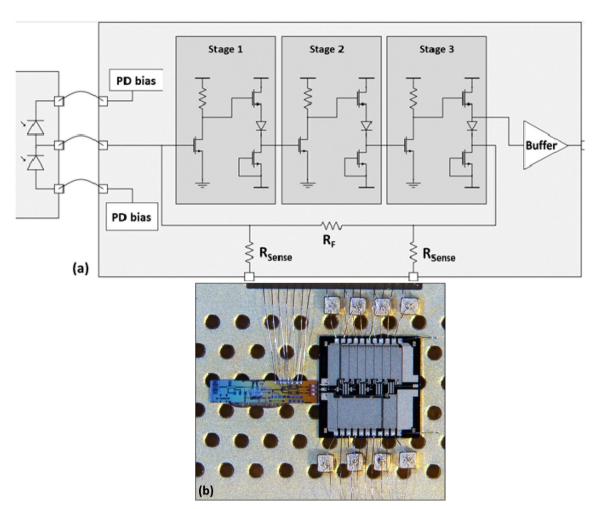


Fig. 4 (a) TIA schematic. (b) Micrograph of the manufactured devices; on the left side is the photonic IC and the on the right side is the TIA.85

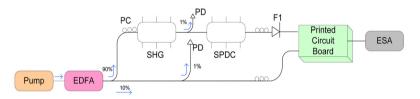


Fig. 5 An integrated detector for squeezing the fiber-coupled source.

squeezing and local oscillator paths. SHG pump power can be adjusted independently of LO with 90% attenuation.89 As a result, residual 780 nm light cannot reach the homodyne detector.90 ESA noise powers were then recorded above 1 s with an 8 MHz resolution bandwidth in zero-span mode. A frequency doubling stage, a parametric downconverter, an amplified telecom pump laser, and a parametric downconverter were used to create the source. 91 As a result, the chip's second input was filled with compressed air.

As a result of the lowering of shot-noise clearing, there is an effective loss in the squeezing at higher frequencies. There was an average of 0.87 0.01 dB of squeezing at 9.2 GHz over a 3 dB bandwidth.⁷⁴ Anti-squeezing levels and measured squeezing with SHG power are shown that are monitored by employing a 99:1 beam splitter in the middle of PPLN modules. 92 The squeezed vacuum's reconstructed Wigner function is shown, which is integrated from 0 to 2 GHz. The phase of the local oscillator was examined at 5 Hz utilizing the on-chip phase shifter. By performing homodyne tomography on-chip of the detected squeezed vacuum, the device's ability to rebuild input quantum states was demonstrated with phase dependence.93

Review Nanoscale

VII. Future perspective

In this section, we present the implementation of silicon photonics in the future. Here we discuss the significance of heterogenous integration and monolithic integration. Moreover, the implementation of silicon photonics for high-speed transmission in a 5G network with minimum power consumption is discussed.

(a) Heterogeneous integration

The silicon photonics manufacturing mechanism is crucial for the future progress and integration of the device. 94 Low-loss waveguides are important to unite the different components of optical in the PIC. The PIC capacity to scale for many components is considerably enhanced by having access to both SiO₂-based waveguides and Si₃N₄-based waveguides. 95 Many applications require a Si₃N₄-based waveguide for coarse wavelength division multiplexer (CWDM) and de- multiplexer, where it enables for temperature-insensitive components.⁹⁶ In many different designs, Ge photodiodes are highly dependable. The potential yield and dependability required for scaling are driven by the ongoing procedure control of these important components. Juniper and Intel have shown diverse integrations of III-V materials such as InP.97 PICs with integrated lasers are evaluated as a possibility for switch capacity to fall below 200 Tbps in the next decade. Temperature-insensitive lasers with Si₃N₄ cavities and Si₃N₄ AWGs significantly encourage to the implementation of dense wavelength division multiplexing (DWDM) systems when compared to the CWDM systems that are currently employed in data centers. 98,99 Hybrid and heterogeneous integration has made significant progress. 100 In these areas, the capabilities of silicon and Si₂N₄ in terms of processing (better lithography and higher temperatures) are being utilized to accomplish magnitude loss minimization (low to 0.1 dB m⁻¹).¹⁰¹

(b) Monolithic integration

Monolithic integration of optical lasers and gain has been a goal in the silicon photonics industry for the past ten years. 102 The achievement of this goal is a constraint with distinct problems, namely: (a) variation in the coefficients of thermal expansion increases to strain cracking and fault migration throughout cooldown; (b) a Si substrate was used to synthesize a polar compound with anti-phase domains. 103 The first constraints can be mainly overcome by better templates and greater containment in the separate heterostructure of the containment (SCH), which in the past lowered the overall epitaxial thickness from 8 μm to merely 4 μm . The eradication of the antiphase domain is implemented in GaAs, GaP, and AIAs layers. 104

(c) Adoption of silicon photonics for data drive applications

Silicon photonics, both as data transmission and sensing technologies, will play a key role in the data-intensive computation facilitated by distributed edge computing and 5G networks. The silicon photonics connectivity will gain

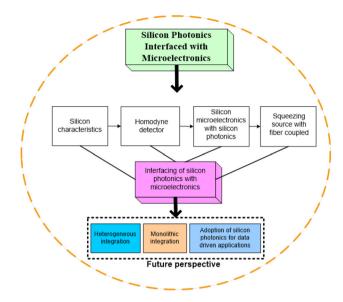


Fig. 6 Graphical view of interfacing silicon photonics with microelectronics.

case applications in the backhaul radio transportation network and radio baseband during the radio access network transitions for maximum throughput. Silicon photonic elements are also becoming a significant computing platform, especially, as Moore's law suffers from the utilization of artificial intelligence (AI) and machine learning (ML) applications with workloads and power consumption.

Another growing topic in silicon photonics is programmable photonic circuits, which employ interoperability in significant and sophisticated Si PICs for diverse optical activities and improve the device setup and control. 110,111 Ultimately, silicon photonics is one of a handful of potential approaches to fulfill quantum computing. Fig. 6 briefly demonstrates the approach of integrating silicon photonics with microelectronics for developing future-generation computers based on quantum technology for achieving high performance and communication. In the future, the wide deployment of silicon photonics assists to achieve high-throughput data-driven applications.

VIII. Conclusion

Silicon photonics interfaced with CMOS microelectronics empowers the implementation of faster data transfer over long distances with low power and high throughput. At present, electrical I/O is used for interconnection between the server board and processors. Every bit of speed-up comes at the cost of significantly increasing power usage. Recent research advances in combining a silicon photonic chip with a silicon microelectronics chip have shown huge promise in taking quantum photonic technology to the next level. Effective measurements of quantum light and the development of advanced detectors and hardware seem to be possible. Many

Nanoscale Review

new applications that include advanced quantum computing and quantum communications are anticipated as a result of such advances.

Conflicts of interest

The authors declare that there is no conflict of interest regarding the publication of this paper.

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